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(54) Title: CONTINUOUS TANGENTIAL FLOW FILTRATION SYSTEM

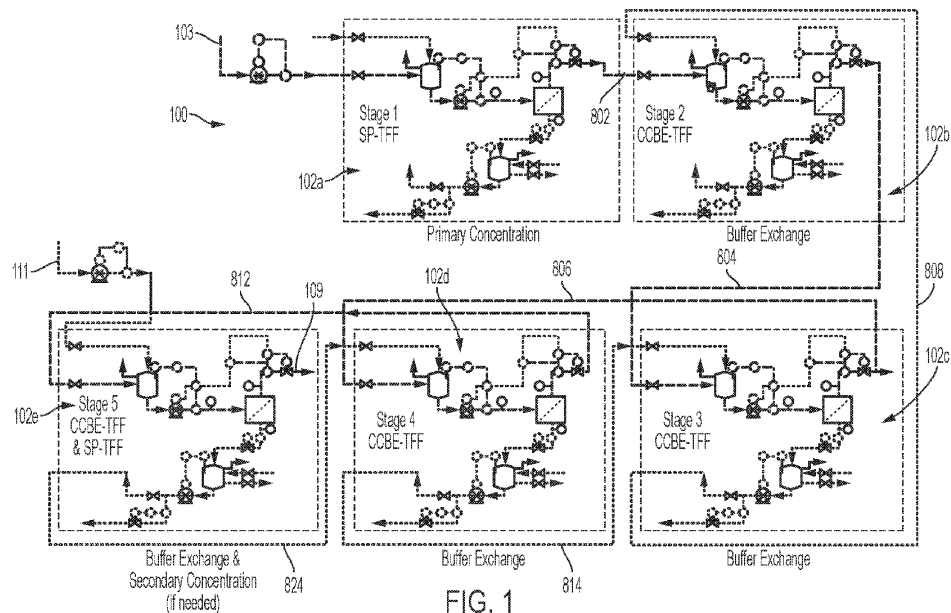


FIG. 1

(57) Abstract: Tangential flow filtration systems and, more specifically, continuous tangential flow filtration ("cTFF") systems comprised of single-pass modules are disclosed herein. Each single-pass module is configured to transition from a first process configuration to a second process configuration and/or operate under both the first process configuration and the second process configuration for customization of the cTFF system. Each of the modules has at least one break tank for regulation of flow and pressure throughout the module and, on a larger scale, the cTFF system.

[Continued on next page]

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- *as to the applicant's entitlement to claim the priority of the earlier application (Rule 4.17(iii))*

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